

Haleakalā National Park Welcomes 2019 Artist In Residence Astrophotographer Stan Honda

HALEAKALĀ NATIONAL PARK, HAWAII, US, February 26, 2019 /EINPresswire.com/ -- Haleakalā National Park and the National Parks Arts Foundation welcome acclaimed night and astro-photographer, Stan Honda, as the 2019 Artist in Residence. Stan Honda is a photojournalist who works with natural landscapes -- usually night time panoramas -- that fuse sky and earth. He will spend the month of March in the park, creating original work based on Haleakala's unique scenery, ecosystems and cultural resources. Honda will hold a public workshop on March 23, 2019 at 5:00 PM at the Headquarters Visitor Center in the Summit District of Haleakalā National Park (7,000 ft. elevation).

New York-based Honda has worked as a photojournalist for 34 years, most recently for Agence France-Presse (AFP). For 16 years at AFP he photographed news and sports around the U.S., including the 9/11 attacks on the World Trade Center, and post-war Iraq from 2003 - 2004.

"We are pleased to again partner with the National Parks Arts Foundation to bring such a talented artist to Haleakalā National Park," said Superintendent Natalie Gates.

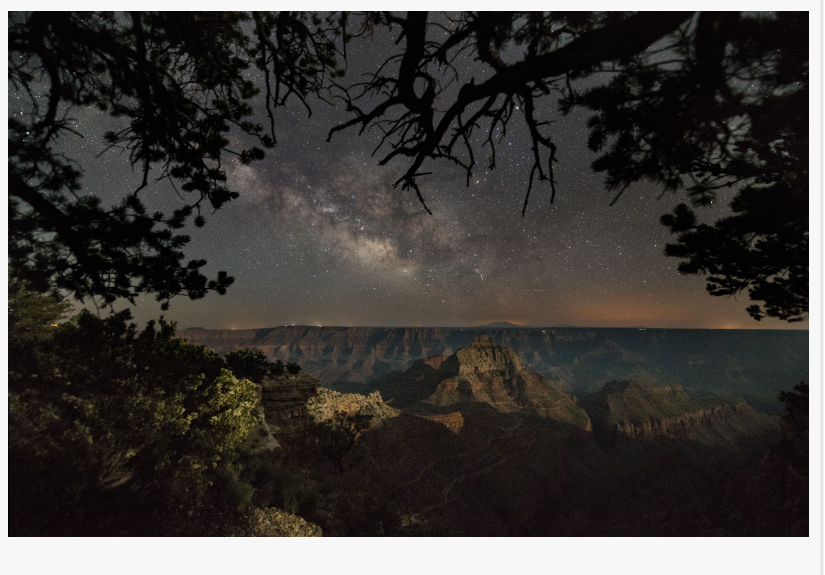
The March 23 event is free to the public (park entrance fee or pass required) and is sponsored in part with a grant from the National Endowment for the Arts. Pre-registration is required - call 808-572-4425 to register.

For updated information visit www.nps.gov/hale or phone (808) 572-4400.

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